



## Supporting Information

for *Adv. Funct. Mater.*, DOI: 10.1002/adfm.202000948

Fermi Level Engineering of Passivation and Electron  
Transport Materials for p-Type  $\text{CuBi}_2\text{O}_4$  Employing a High-  
Throughput Methodology

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# Fermi Level Engineering of Passivation and Electron Transport Materials for p-type $\text{CuBi}_2\text{O}_4$ Employing A High Throughput Methodology

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**Keywords:** p-type semiconductor, passivation layer, high-throughput methodology, fermi level engineering, solar photochemistry

Supporting Figures:

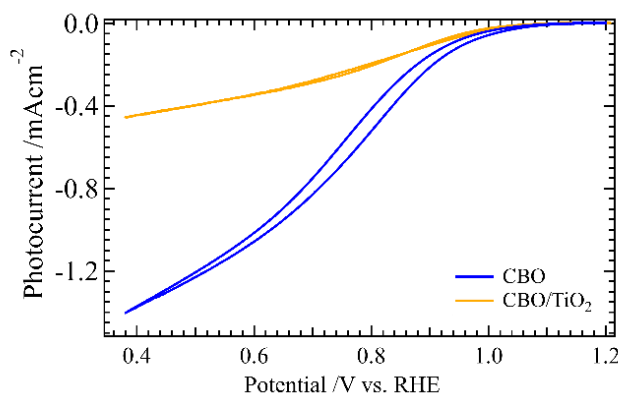


Figure S1. The J-V response of CBO photocathode before (blue) and after (orange) 2 nm  $\text{TiO}_2$  overlayer deposition by ALD.

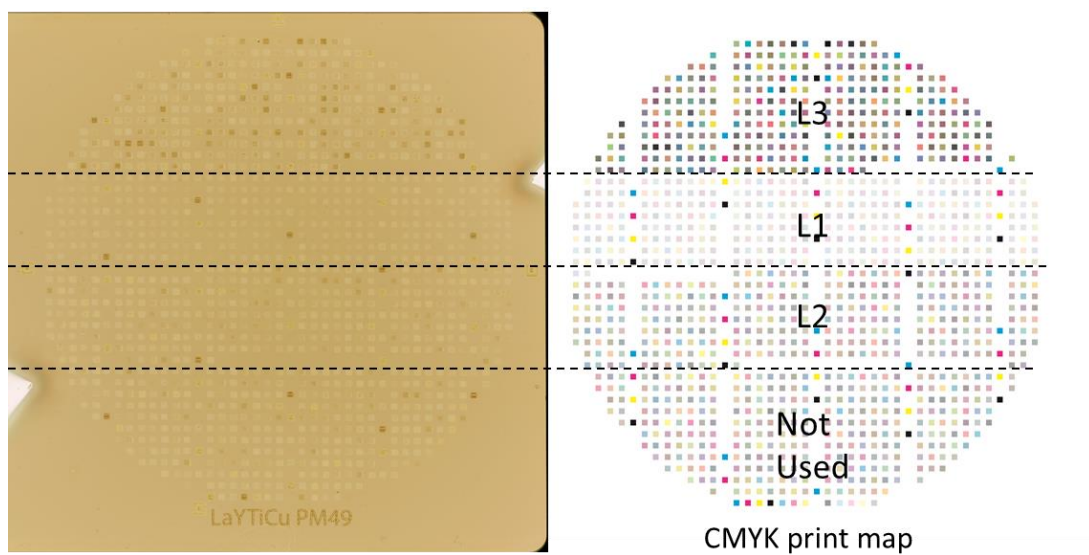


Figure S2. Photo image of the La:Y:Ti:Cu oxide coating library on CBO/FTO film with the corresponding print map indicating the different loading regions.

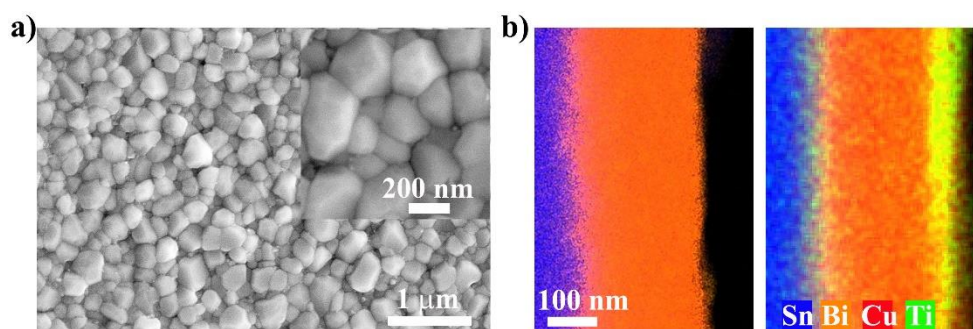


Figure S3. SEM image of CBO sample with  $\text{Cu}_x\text{Ti}_y\text{O}_z$  overlayer (a); high resolution cross-section EDX mapping of CBO and CBO/ $\text{Cu}_x\text{Ti}_y\text{O}_z$  samples (b).

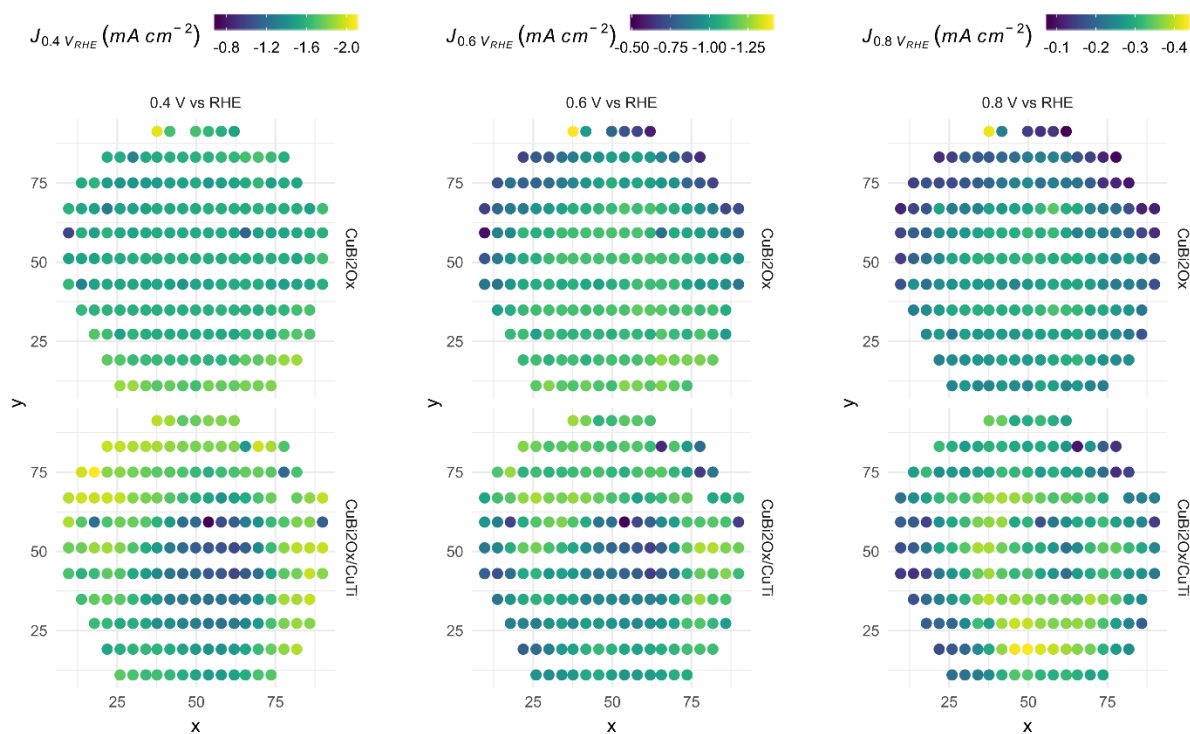


Figure S4. The photocurrent maps of CBO (top, a, c, e) and CBO/Cu<sub>x</sub>Ti<sub>y</sub>O<sub>z</sub> (bottom, b, d, f) photocathodes under different applied potential.

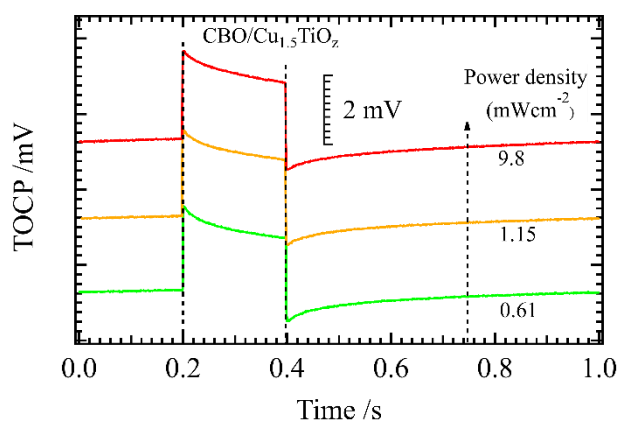


Figure S5. Transient open-circuit potential measurements of CBO/Cu<sub>1.5</sub>TiO<sub>z</sub> film under continuous white light bias and pulsed blue light with variable density in 0.1 M KHCO<sub>3</sub>

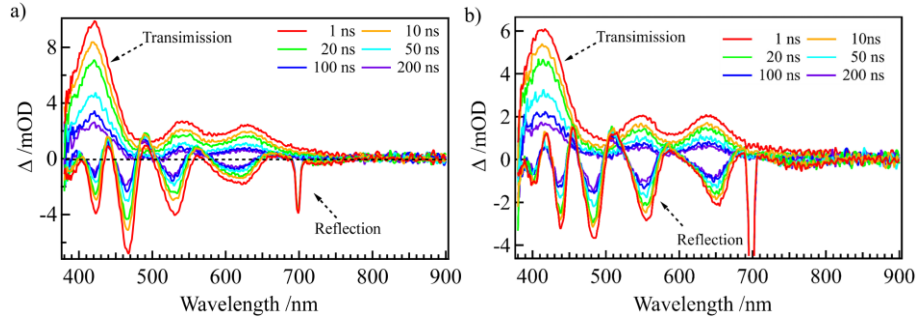


Figure S6. Differential transmission (dT) and differential reflection spectra (dR) of CBO (a) and CBO/Cu<sub>1.5</sub>TiO<sub>2</sub> (b) film films at various pump-probe delays.

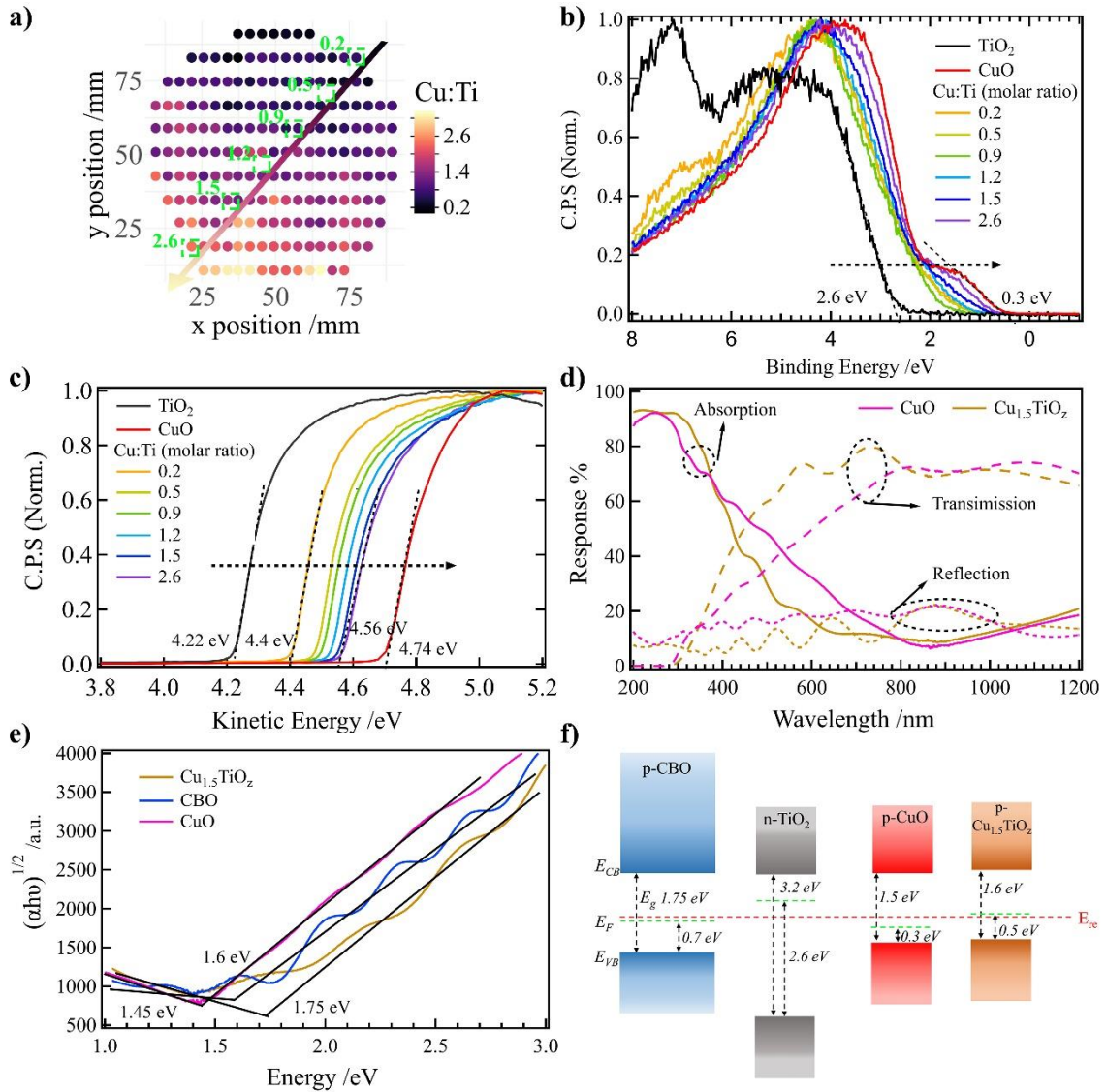


Figure S7. The composition map of Cu<sub>x</sub>Ti<sub>y</sub>O<sub>z</sub> overlay showing the six selected points with Cu:Ti ratio of 0.2, 0.5, 0.9, 1.2, 1.5, and 2.6(a); the Valence band edge (b) and second electron cut-off spectra

of the six selected points, CBO,  $\text{TiO}_2$ , and CuO (c); Transmission, reflection and absorption spectroscopy of CuO and  $\text{Cu}_{1.5}\text{TiO}_z$  films (d); Tauc plots of CuO, CBO, and  $\text{Cu}_{1.5}\text{TiO}_z$  films (e); Band alignment of CBO,  $\text{TiO}_2$ , CuO, and  $\text{Cu}_{1.5}\text{TiO}_z$  films (f) in electrolyte containing 0.1 M  $\text{KHCO}_3$  and 0.1 M  $\text{Na}_2\text{S}_2\text{O}_8$  (pH=8.2) with reduction potential ( $E_{\text{re}}$ ) at 0.12  $V_{\text{RHE}}$  (-4.56  $V_{\text{vacuum}}$ ).

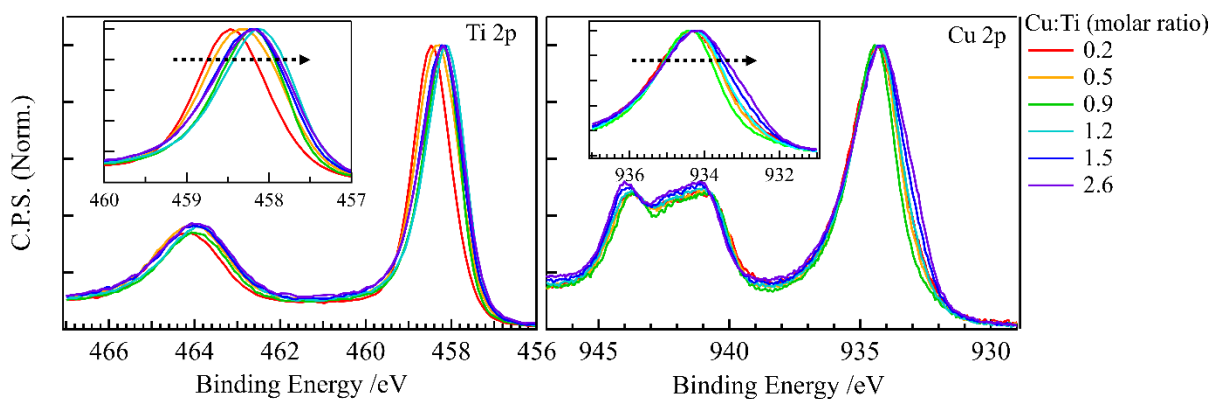


Figure S8. The core-level XPS spectra of Ti 2p and Cu 2p for  $\text{Cu}_x\text{Ti}_y\text{O}_z$  overlayer with six selected Cu:Ti ratios.

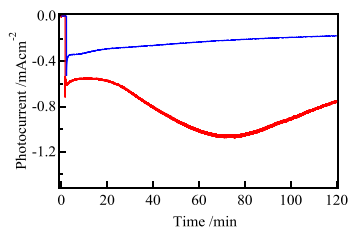


Figure S9. The J-t curves of CBO (blue) and  $\text{CBO}/\text{Cu}_{1.5}\text{TiO}_z$  (red) photocathode at 0.8  $V_{\text{RHE}}$  under blue LED illumination over the course of 120 min.

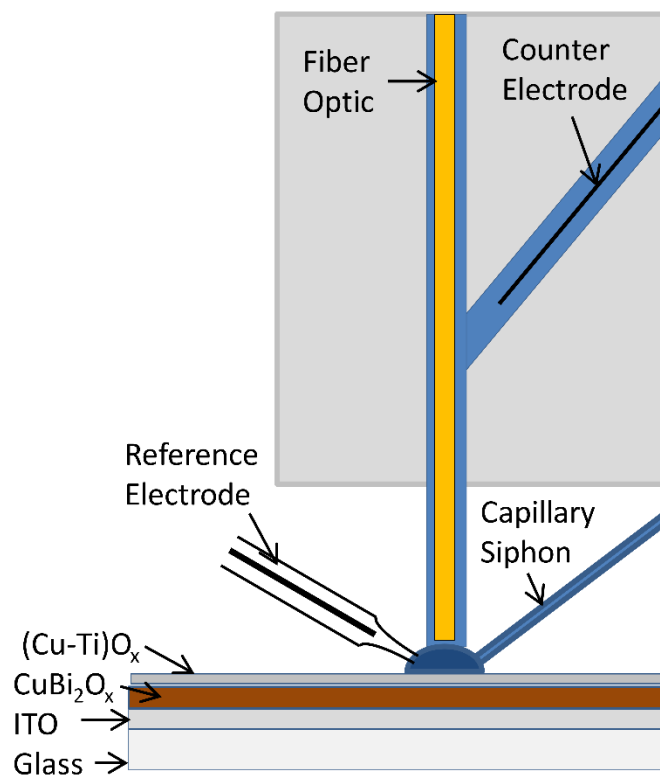


Figure S10. Cross-sectional diagram of the scanning droplet cell.